



Sheet 1 of 1

Form 1449*

INFORMATION DISCLOSURE STATEMENT
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Atty. Docket No.: 303.648US1

Serial No. 09/484,303

Applicant: Kie Y. Ahn et al.

Filing Date: January 18, 2000

Group: 2825

U. S. PATENT DOCUMENTS

**Examiner Initial	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
NB	4,565,157✓	01/21/1986	Brors, D.L., et al.	118	719	03/29/83
NB	4,847,111✓	07/11/1989	Chow, Y.C., et al.	427	38	06/30/88
NB	5,084,412✓	01/28/1992	Nakasaki, Y.	437	189	10/01/90
NB	5,231,056✓	07/27/1993	Sandhu, G.S.	437	200	01/15/92
NB	5,654,245✓	08/05/1997	Allen, G.L.	438	629	03/23/93
NB	5,670,420✓	09/23/1997	Choi, K.K.	437	189	11/08/95
NB	5,763,953✓	06/09/1998	Iljima, T., et al.	257	762	01/18/96
NB	5,824,599✓	10/20/1998	Schacham-Diamond, et al.	438	678	01/16/96
NB	5,948,467✓	09/07/1999	Nguyen, T., et al.	427	99	07/24/98
NB	6,017,820✓	01/25/2000	Ting, C.H., et al.	438	689	07/17/98
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FOREIGN PATENT DOCUMENTS

**Examiner Initial	Document Number	Date	Country	Class	Subclass	Translation Yes	Translation No
NB	07078815✓	03/20/1995	Japan	HO1L	21/3205		

OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)

NB	Shacham-Diamond, Y., et al., "Copper electroless deposition technology for ultra-large-scale-intergration (ULSI) metallization", <u>Microelectronic Engineering</u> , NL, Vol. 33, No. 1, XP004054497, 47-58, (1997) ✓
NB	Stroud, P.T., et al., "Preferential deposition of silver induced by low energy gold ion implantation", <u>Thin Solid Films</u> , Switzerland, Vol. 9, No. 2, XP000993098, 273-281, (Feb. 1972)

Examiner Neal Benenzay

Date Considered

3-22-03

*Substitute Disclosure Statement Form (PTO-1449)

**EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.